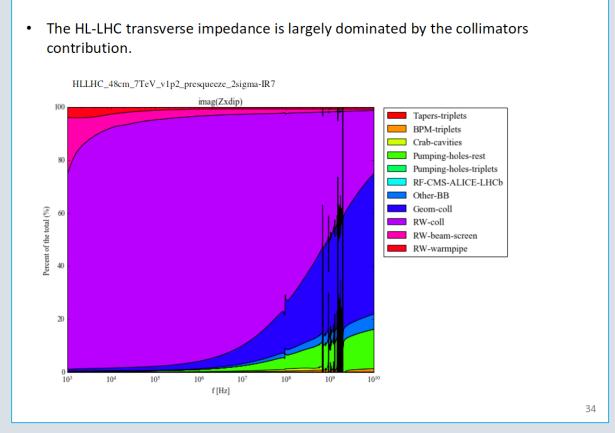
Low-impedance collimators for HL-LHC

S. ANTIPOV, N. BIANCACCI, E. METRAL

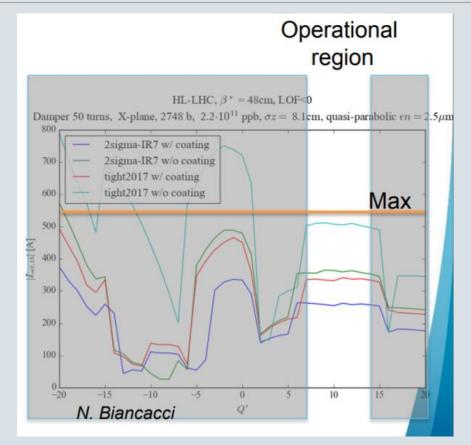
MANY THANKS TO ALESSIO, BENOIT, DAVID, STEFANO, RODERIK

Motivation



N. Biancacci, et al., Impedance Measurements of Low Impedance Collimator, HL-LHC TCC, 30.03.2017

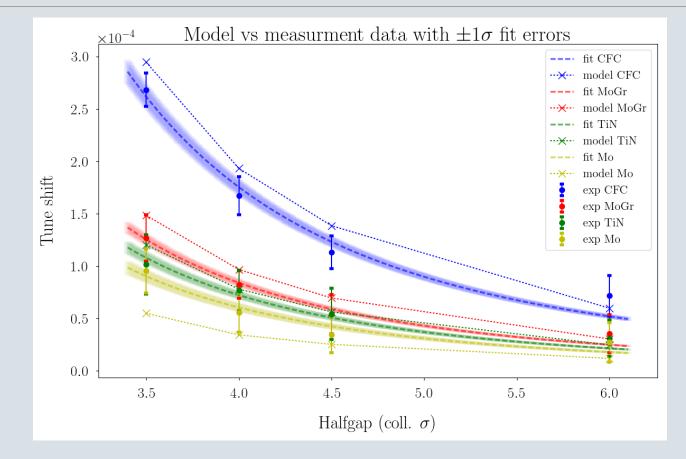
Reduction of impedance is needed to ensure beam stability at higher intensities



R. Bruce, Is collimation still a limitation for HL-LHC?, Chamonix, Jan. 2017

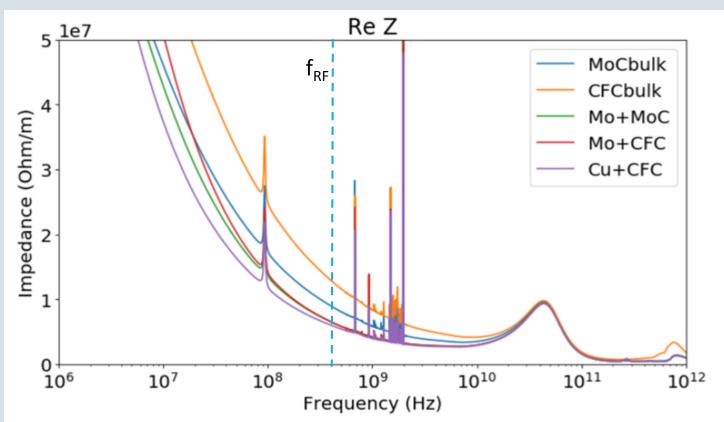
LOW-IMPEDANCE COLLIMATORS

Mo coating significantly reduces the impedance of a collimator



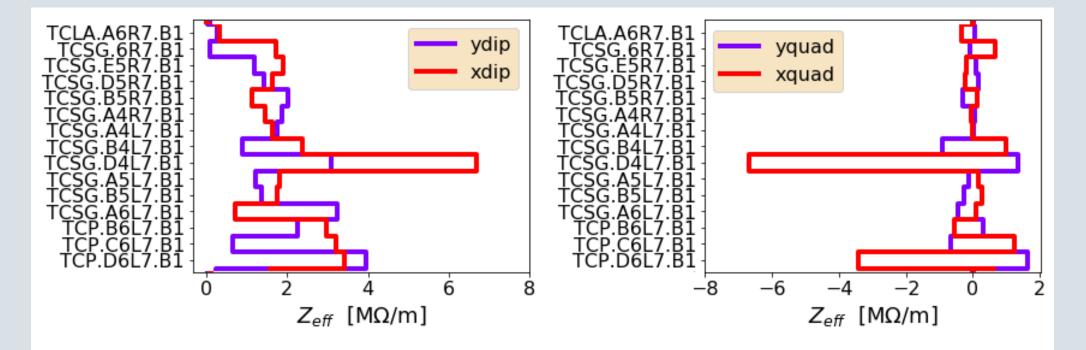
50% decrease of the impedance with Mo coated TCSGs

Using MoGr bulk gives ½ of the improvement



4 TCSGs to be upgraded to Mo + MoGr during LS2

Which ones?



Comparing coating scenarios for IR-7

Goal: Max reduction of impedance, octupole current

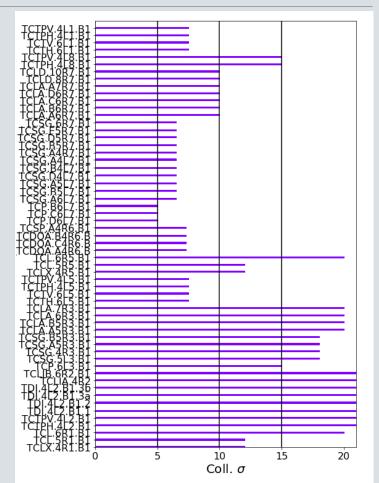
48 cm optics

Tight collimator settings

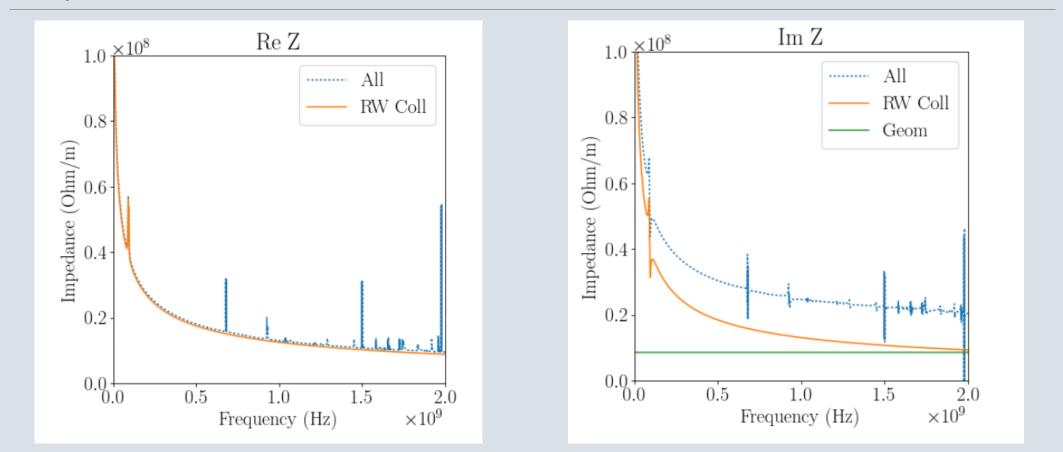
 $\circ~$ 1.5 σ retraction of the secondaries

2.5 µm emittance, 8.1 cm bunch length

Negative octupole polarity

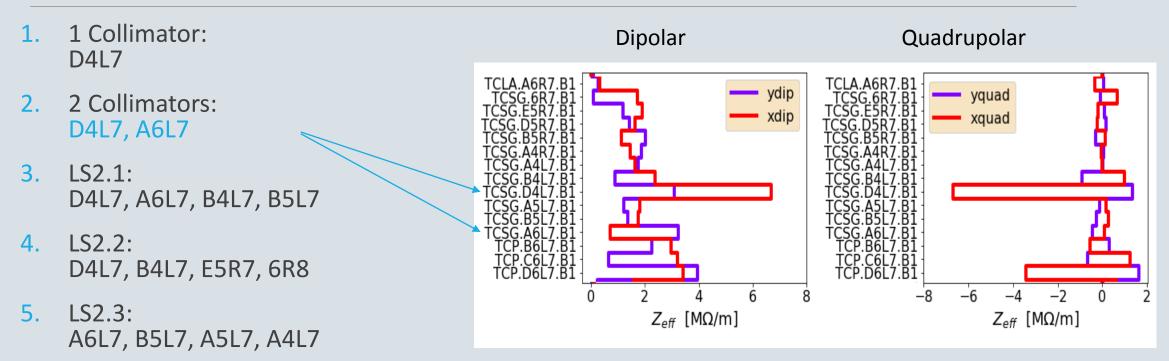


We should not forget about the geometric impedance

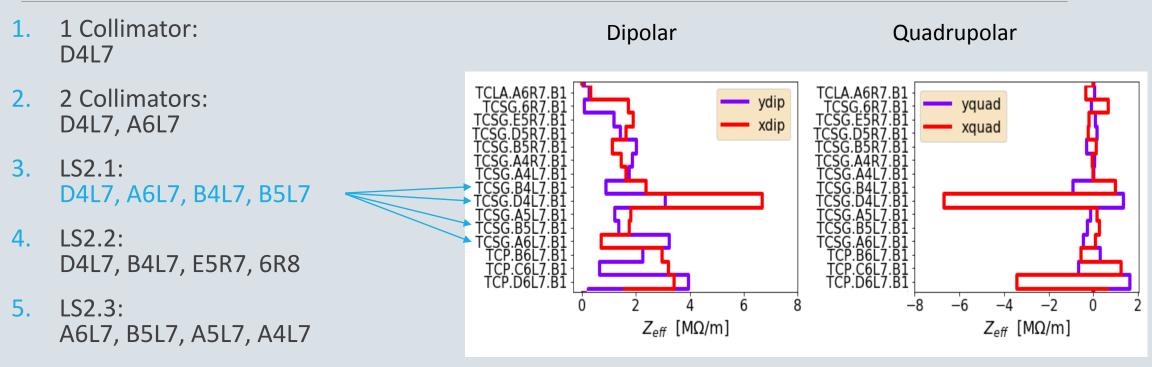


Using Im Z for the impedance comparison

- 1 Collimator: 1. Quadrupolar Dipolar D4L7 TCLA.A6R7.B1 TCLA.A6R7.B1 ydip yquad 2 Collimators: 2. xdip xquad D4L7, A6L7 3. LS2.1: D4L7, A6L7, B4L7, B5L7 **4**. LS2.2: D4L7, B4L7, E5R7, 6R8 -6 6 5. LS2.3: Z_{eff} [M Ω /m] Z_{eff} [M Ω /m] A6L7, B5L7, A5L7, A4L7
- 6. LS2.4: D4L7, A6L7, B5L7, A5L7



6. LS2.4: D4L7, A6L7, B5L7, A5L7



6. LS2.4: D4L7, A6L7, B5L7, A5L7

- 1. 1 Collimator: Dipolar Quadrupolar D4L7 TCLA.A6R7.B1 TCLA.A6R7.B ydip yquad 2 Collimators: 2. xdip xquad D4L7, A6L7 **3**. LS2.1: D4L7, A6L7, B4L7, B5L7 **4**. LS2.2: D4L7, B4L7, E5R7, 6R7 -6 6 5. LS2.3: Z_{eff} [M Ω /m] Z_{eff} [M Ω /m] A6L7, B5L7, A5L7, A4L7
- 6. LS2.4: D4L7, A6L7, B5L7, A5L7

Avoiding the skew collimators most exposed to steady losses

- 1 Collimator: 1. Dipolar Quadrupolar D4L7 2 Collimators: TCLA.A6R7.B 2. FCLA.A6R7.B ydip yquad D4L7, A6L7 xdip xquad **3**. LS2.1: D4L7, A6L7, B4L7, B5L7 **4**. LS2.2: D4L7, B4L7, E5R7, 6R8 5. LS2.3: 6 -6 -8 Z_{eff} [M Ω /m] Z_{eff} [M Ω /m] A6L7, B5L7, A5L7, A4L7
- 6. LS2.4: D4L7, A6L7, B5L7, A5L7

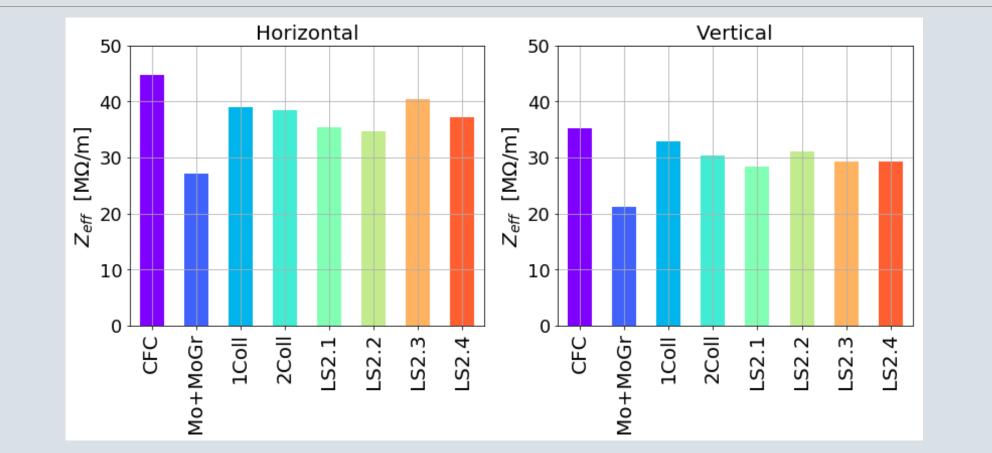
Avoiding hor. and vert. ones for protection reasons

- 1. 1 Collimator: Dipolar Quadrupolar D4L7 2 Collimators: TCLA.A6R7.B 2. FCLA.A6R7.B ydip yquad D4L7, A6L7 xdip xquad 3. LS2.1: D4L7, A6L7, B4L7, B5L7 **4**. LS2.2: D4L7, B4L7, E5R7, 6R8 5. LS2.3: 6 -6 -8 Z_{eff} [M Ω /m] Z_{eff} [M Ω /m] A6L7, B5L7, A5L7, A4L7
 - Avoiding hor. only for protection at the top energy

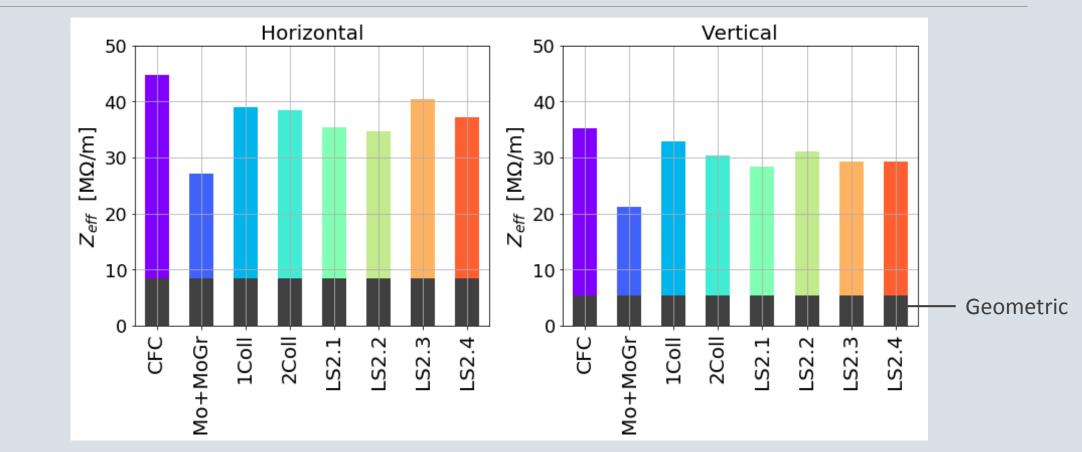
6. LS2.4:

D4L7, A6L7, B5L7, A5L7

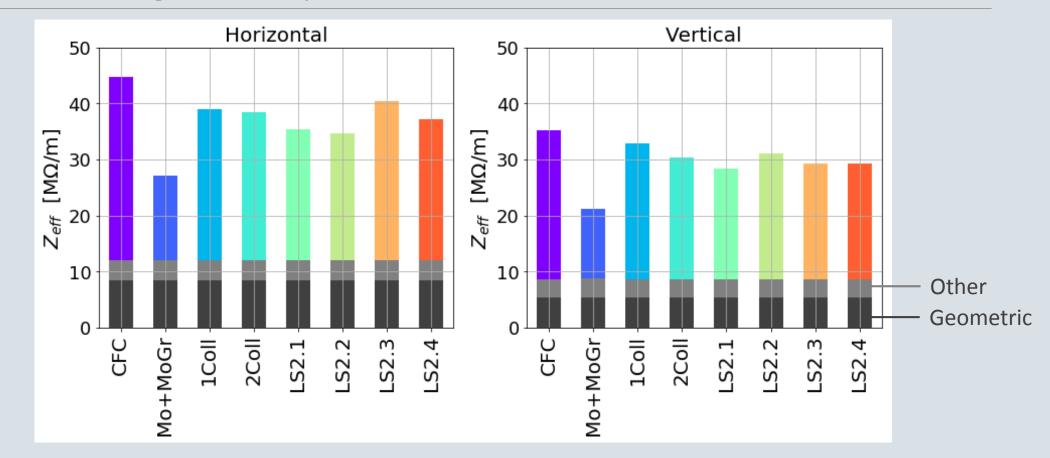
Total machine impedance can be decreased by 10-20% using a subset of collimators. Can be done with just 1-2 units



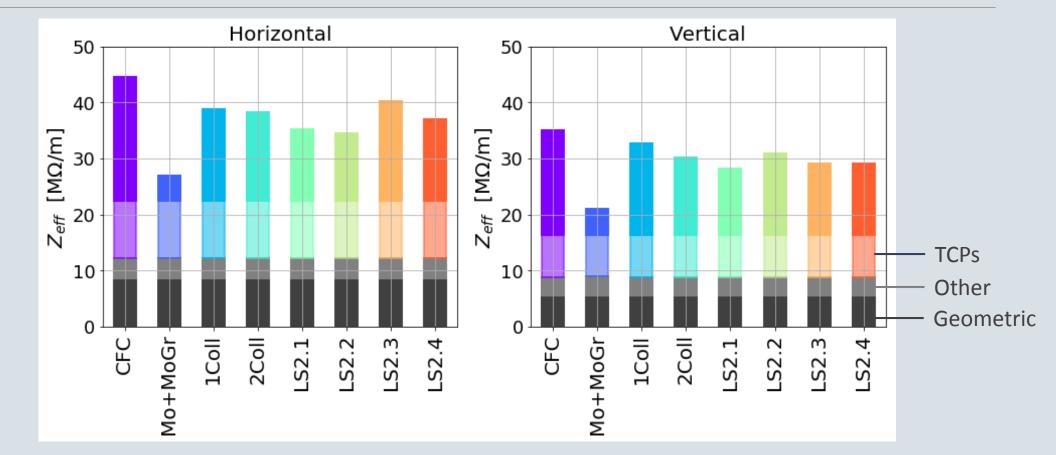
Total machine impedance can be decreased by 10-20% using a subset of collimators. Can be done with just 1-2 units



Resistive wall contribution to the machine impedance can be decreased significantly

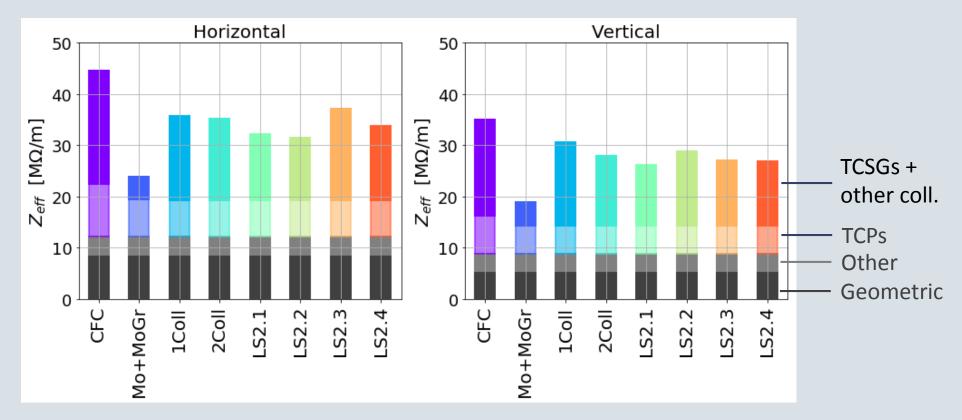


Resistive wall contribution of the secondary collimators can be decreased by 50% using a subset

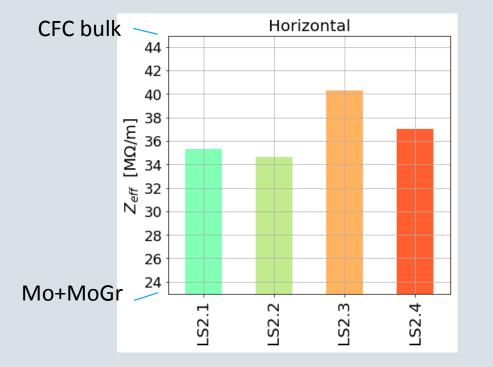


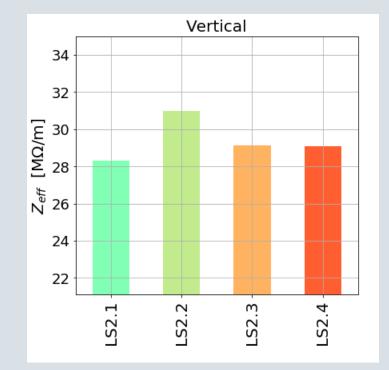
Additional decrease can be achieved from coating the TCPs

2 TCPs: H and V in the IR-7 region to be replaced by MoGr bulk during the LS2

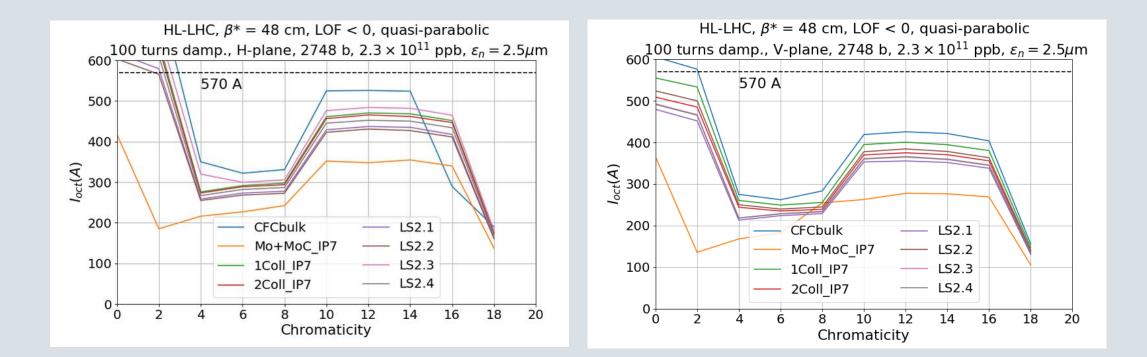


The 2nd option for LS2 offers the largest impedance reduction in the more critical H-plane

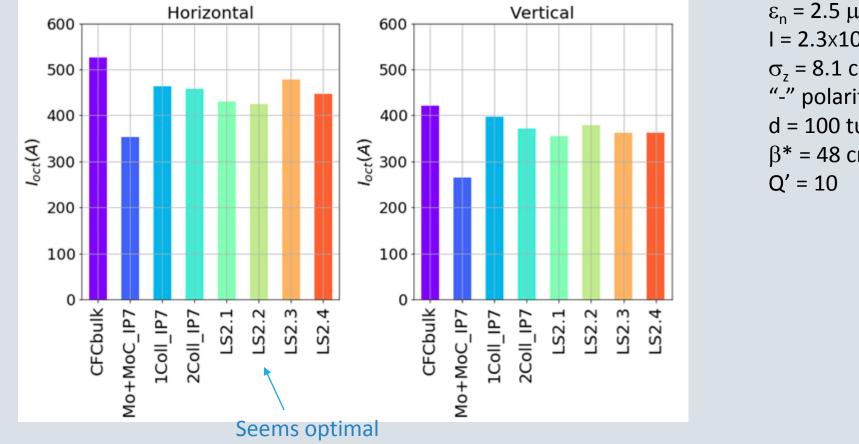




Without the coating the required octupole current is close to the limit



Considerable, up to 100 A decrease of the octupole threshold for the partial coating



 $\varepsilon_n = 2.5 \ \mu m$ I = 2.3×10¹¹ ppb $\sigma_{7} = 8.1 \text{ cm}$ "-" polarity d = 100 turns $\beta^* = 48 \text{ cm}$

Summary

Using Mo coating on TCSGs in IR-7 one can reduce the machine impedance and octupole threshold by ~ 30%

A half of the reduction can be achieved with a subset of 4 collimators

For the tight collimator scenario one can reduce the octupole current by

- 200 A by coating all the TCSGs in IR-7
- Up to 100 A by coating a subset

The option LS2.2 is the most preferable from the beam stability point of view



Resistivity of the materials

Material	IW2D Model (Used)	From the TCSPM MD*
CFC	5000 nΩxm	3950 ± 350 nΩxm
MoGr	1000 nΩxm	690 ± 70 nΩxm
TiN	400 nΩxm	310 ± 30 nΩxm
Мо	50 nΩxm	130 ± 20 nΩxm

The fits of the experimental data accounted for only the RW contribution, no geometric Probably good to 10-20 %

* To be discussed in detail at the Impedance WG Meeting on 25.08.17

The bigger (collimator impedance) picture

